

HAT2218R

Silicon N Channel Power MOS FET with Schottky Barrier Diode High Speed Power Switching

REJ03G0396-0300

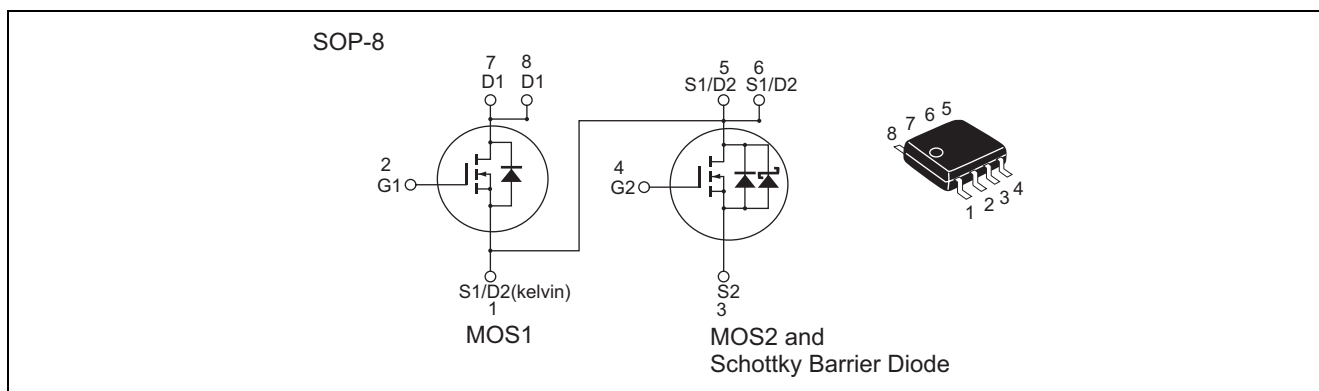
Rev.3.00

Aug.23.2004

Features

- Low on-resistance
- Capable of 4.5 V gate drive
- High density mounting
- Built-in Schottky Barrier Diode

Outline



Absolute Maximum Ratings

(Ta = 25°C)

Item	Symbol	Ratings		Unit
		MOS1	MOS2 & SBD	
Drain to source voltage	V_{DSS}	30	30	V
Gate to source voltage	V_{GSS}	± 20	± 12	V
Drain current	I_D	7.5	8.0	A
Drain peak current	$I_{D(pulse)}$ ^{Note1}	60	64	A
Reverse drain current	I_{DR}	7.5	8.0	A
Channel dissipation	P_{ch} ^{Note2}	1.5	1.5	W
Channel temperature	T_{ch}	150	150	°C
Storage temperature	T_{stg}	-55 to +150	-55 to +150	°C

Notes: 1. $PW \leq 10 \mu s$, duty cycle $\leq 1 \%$

2. 1 Drive operation; When using the glass epoxy board (FR4 40 x 40 x 1.6 mm), $PW \leq 10 s$

Electrical Characteristics

• MOS1

(Ta = 25°C)

Item	Symbol	Min	Typ	Max	Unit	Test Conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	30	—	—	V	$I_D = 10 \text{ mA}, V_{GS} = 0$
Gate to source leak current	I_{GSS}	—	—	± 0.1	μA	$V_{GS} = \pm 20 \text{ V}, V_{DS} = 0$
Zero gate voltage drain current	I_{DSS}	—	—	1	μA	$V_{DS} = 30 \text{ V}, V_{GS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	1.0	—	2.5	V	$V_{DS} = 10 \text{ V}, I_D = 1 \text{ mA}$
Static drain to source on state resistance	$R_{DS(on)}$	—	19	24	$\text{m}\Omega$	$I_D = 3.75 \text{ A}, V_{GS} = 10 \text{ V}$ ^{Note3}
	$R_{DS(on)}$	—	27	40	$\text{m}\Omega$	$I_D = 3.75 \text{ A}, V_{GS} = 4.5 \text{ V}$ ^{Note3}
Forward transfer admittance	$ y_{fs} $	9	15	—	S	$I_D = 3.75 \text{ A}, V_{DS} = 10 \text{ V}$ ^{Note3}
Input capacitance	C_{iss}	—	630	—	pF	$V_{DS} = 10 \text{ V}$
Output capacitance	C_{oss}	—	155	—	pF	$V_{GS} = 0$
Reverse transfer capacitance	C_{rss}	—	57	—	pF	$f = 1 \text{ MHz}$
Total gate charge	Q_g	—	4.6	—	nC	$V_{DD} = 10 \text{ V}$
Gate to source charge	Q_{gs}	—	2.2	—	nC	$V_{GS} = 4.5 \text{ V}$
Gate to drain charge	Q_{gd}	—	1.2	—	nC	$I_D = 7.5 \text{ A}$
Turn-on delay time	$t_{d(on)}$	—	7	—	ns	$V_{GS} = 10 \text{ V}, I_D = 3.75 \text{ A}$
Rise time	t_r	—	14	—	ns	$V_{DD} \approx 10 \text{ V}$
Turn-off delay time	$t_{d(off)}$	—	36	—	ns	$R_L = 2.66 \Omega$
Fall time	t_f	—	3.4	—	ns	$R_g = 4.7 \Omega$
Body-drain diode forward voltage	V_{DF}	—	0.85	1.11	V	$I_F = 7.5 \text{ A}, V_{GS} = 0$ ^{Note3}
Body-drain diode reverse recovery time	t_{rr}	—	17	—	ns	$I_F = 7.5 \text{ A}, V_{GS} = 0$ $diF/dt = 100 \text{ A}/\mu\text{s}$

Notes: 3. Pulse test

• MOS2 & Schottky Barrier Diode

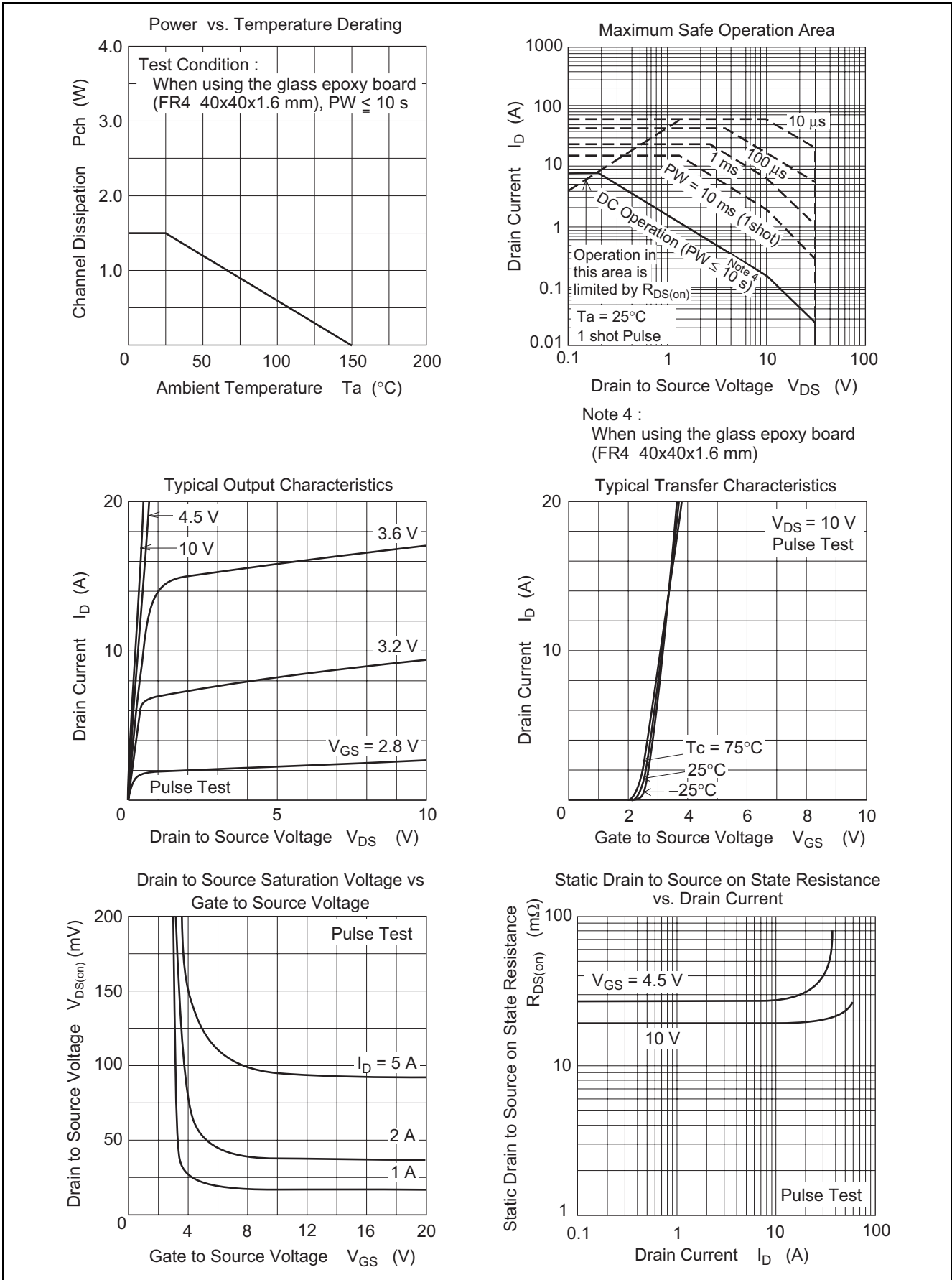
(Ta = 25°C)

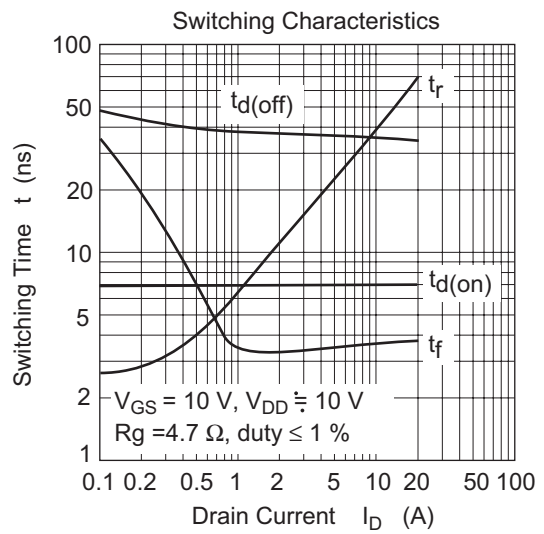
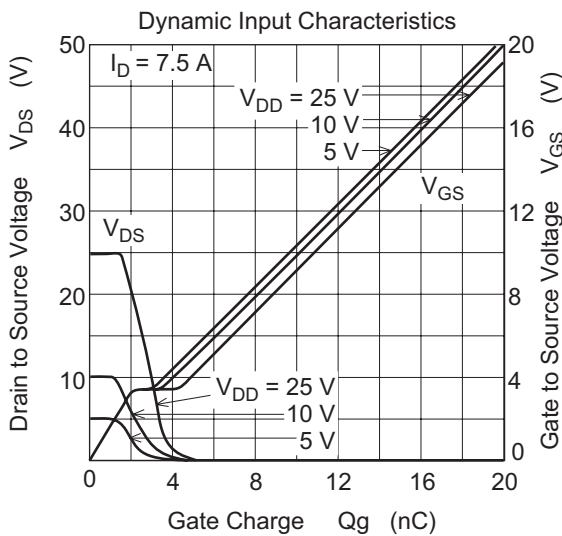
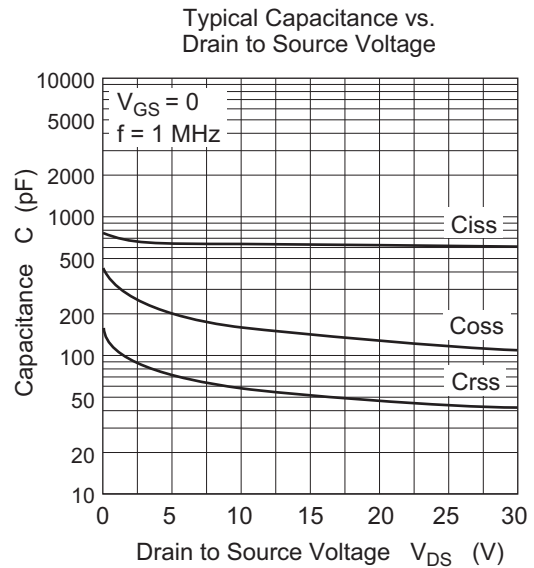
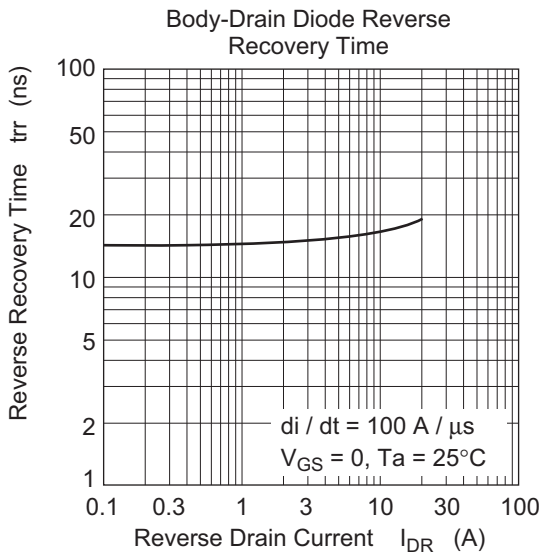
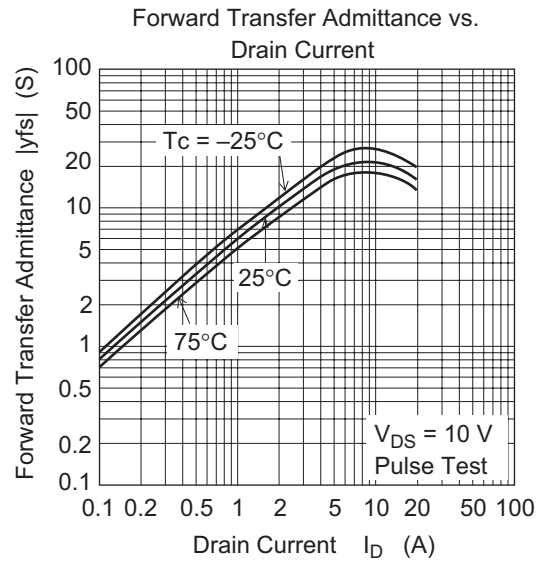
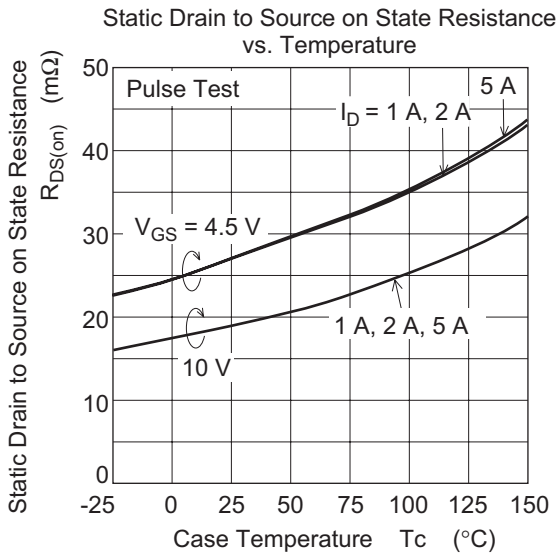
Item	Symbol	Min	Typ	Max	Unit	Test Conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	30	—	—	V	$I_D = 10 \text{ mA}, V_{GS} = 0$
Gate to source leak current	I_{GSS}	—	—	± 0.1	μA	$V_{GS} = \pm 12 \text{ V}, V_{DS} = 0$
Zero gate voltage drain current	I_{DSS}	—	—	1	mA	$V_{DS} = 30 \text{ V}, V_{GS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	1.4	—	2.5	V	$V_{DS} = 10 \text{ V}, I_D = 1 \text{ mA}$
Static drain to source on state resistance	$R_{DS(on)}$	—	17	22	$\text{m}\Omega$	$I_D = 4 \text{ A}, V_{GS} = 10 \text{ V}$ ^{Note3}
	$R_{DS(on)}$	—	21	29	$\text{m}\Omega$	$I_D = 4 \text{ A}, V_{GS} = 4.5 \text{ V}$ ^{Note3}
Forward transfer admittance	$ y_{fs} $	15	25	—	S	$I_D = 4 \text{ A}, V_{DS} = 10 \text{ V}$ ^{Note3}
Input capacitance	C_{iss}	—	1330	—	pF	$V_{DS} = 10 \text{ V}$
Output capacitance	C_{oss}	—	230	—	pF	$V_{GS} = 0$
Reverse transfer capacitance	C_{rss}	—	92	—	pF	$f = 1 \text{ MHz}$
Total gate charge	Q_g	—	11	—	nC	$V_{DD} = 10 \text{ V}$
Gate to source charge	Q_{gs}	—	3.8	—	nC	$V_{GS} = 4.5 \text{ V}$
Gate to drain charge	Q_{gd}	—	3.2	—	nC	$I_D = 8 \text{ A}$
Turn-on delay time	$t_{d(on)}$	—	10	—	ns	$V_{GS} = 10 \text{ V}, I_D = 4 \text{ A}$
Rise time	t_r	—	16	—	ns	$V_{DD} \approx 10 \text{ V}$
Turn-off delay time	$t_{d(off)}$	—	43	—	ns	$R_L = 2.5 \Omega$
Fall time	t_f	—	3.9	—	ns	$R_g = 4.7 \Omega$
Schottky Barrier diode forward voltage	V_F	—	0.5	—	V	$I_F = 3.5 \text{ A}, V_{GS} = 0$ ^{Note3}
Body-drain diode reverse recovery time	t_{rr}	—	15	—	ns	$I_F = 8 \text{ A}, V_{GS} = 0$ $diF/dt = 100 \text{ A}/\mu\text{s}$

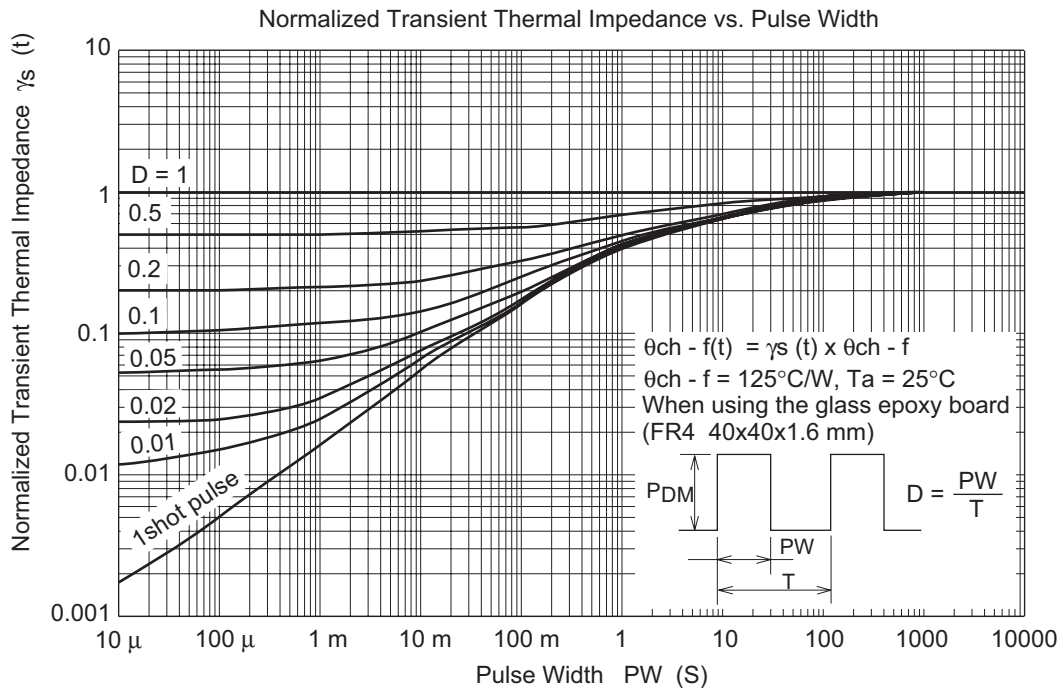
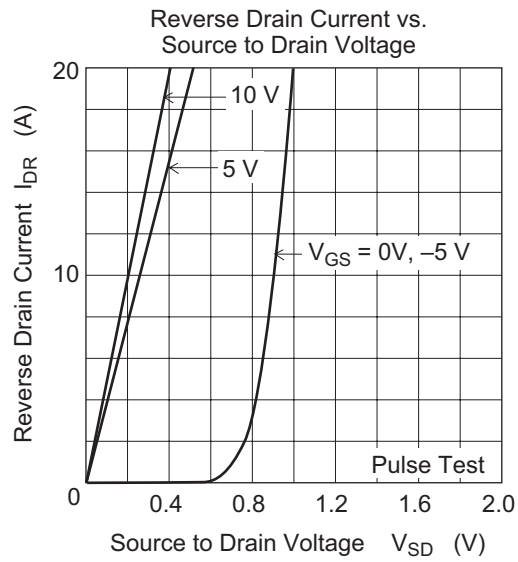
Notes: 3. Pulse test

Main Characteristics

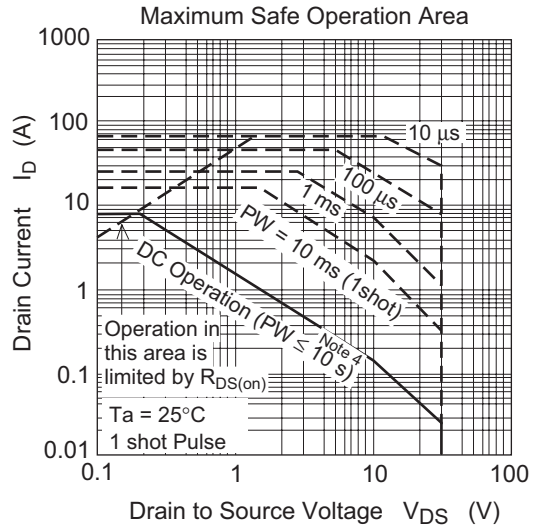
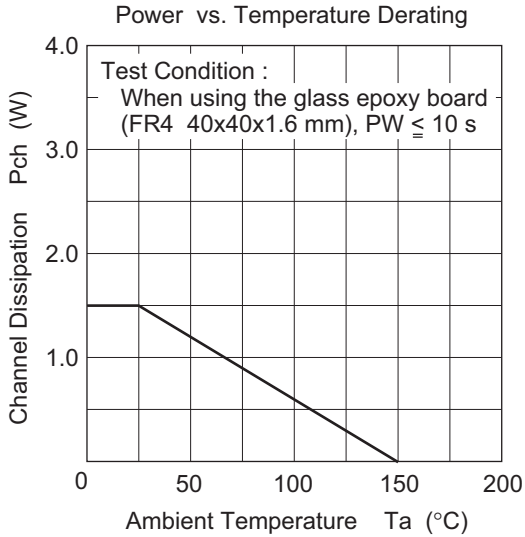
• MOS1



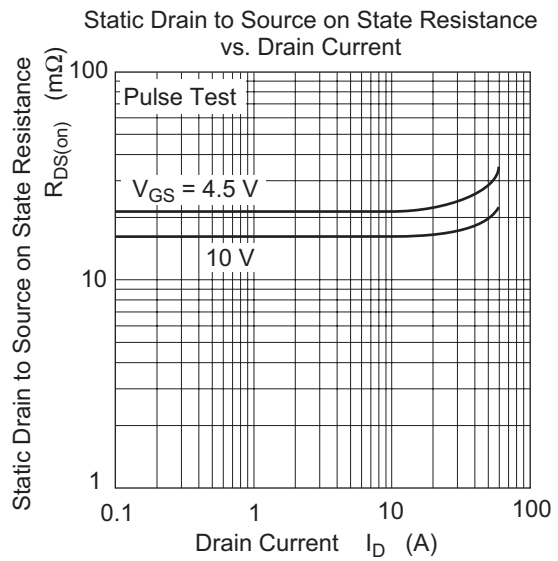
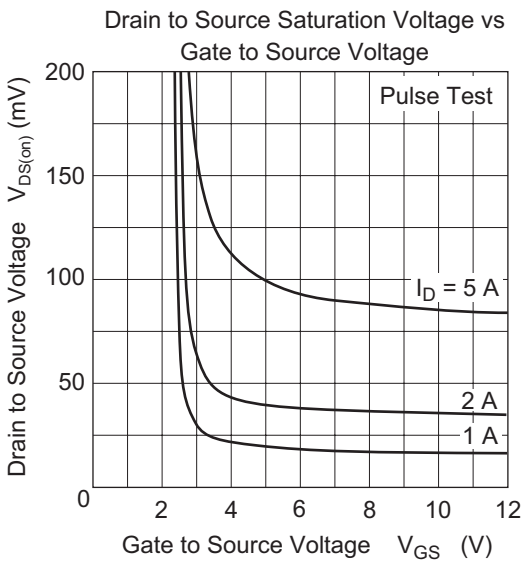
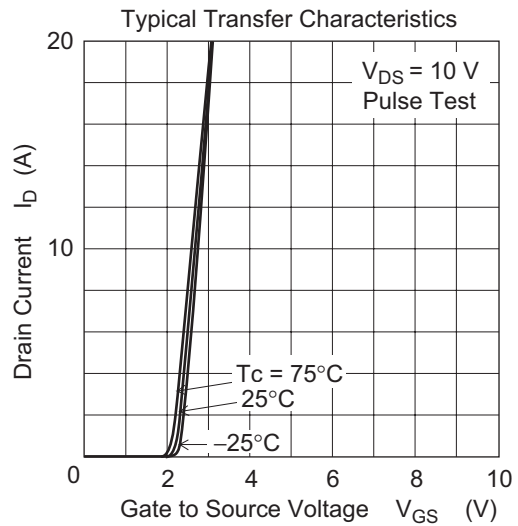
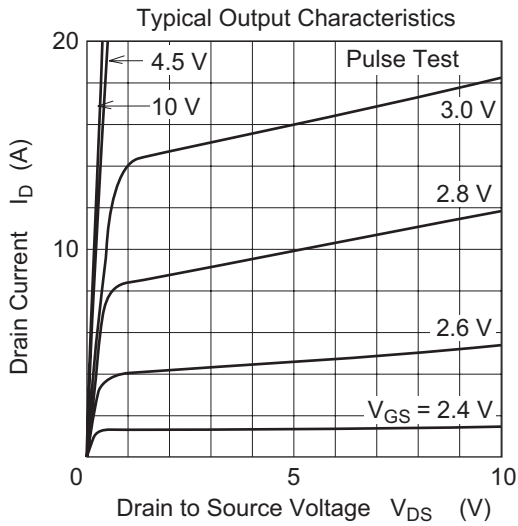


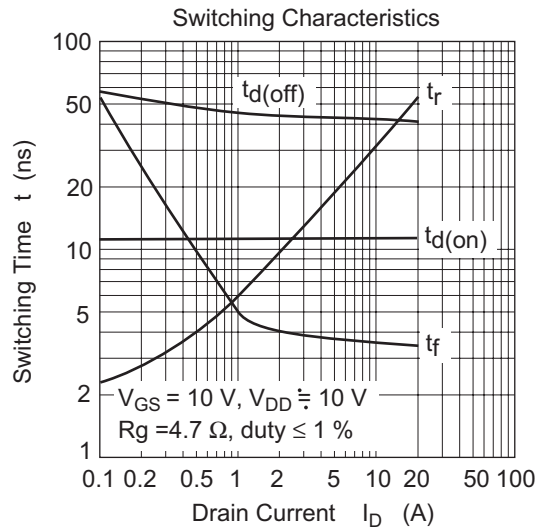
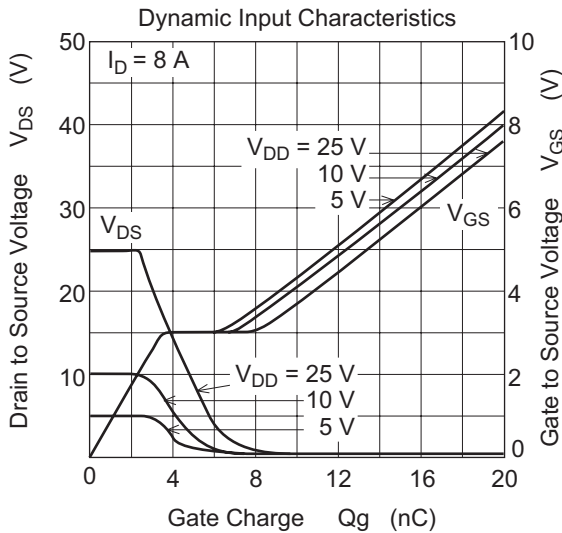
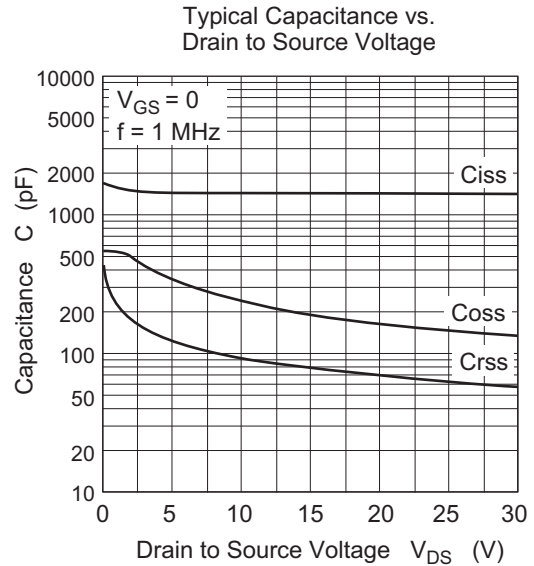
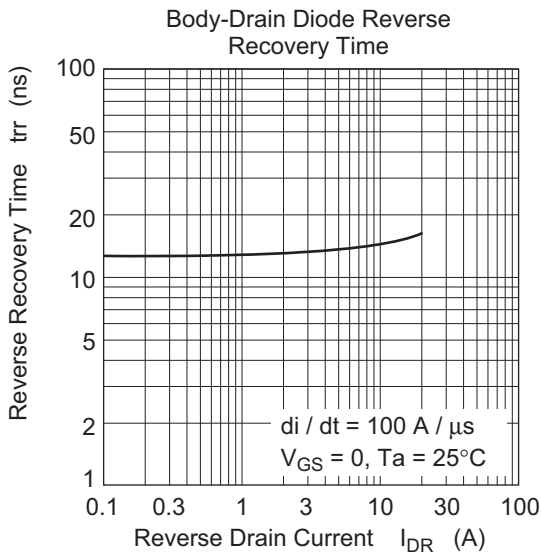
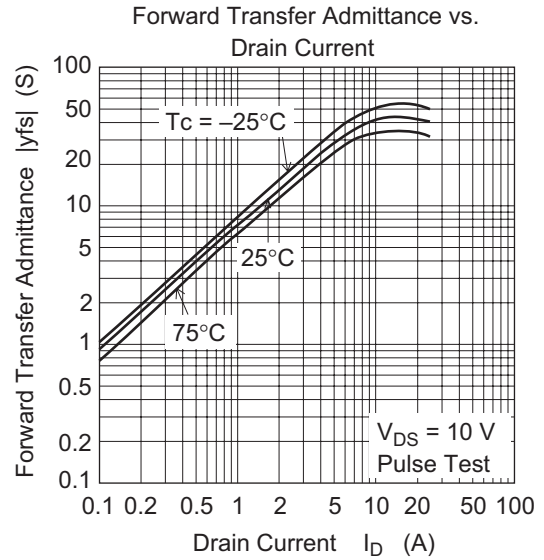
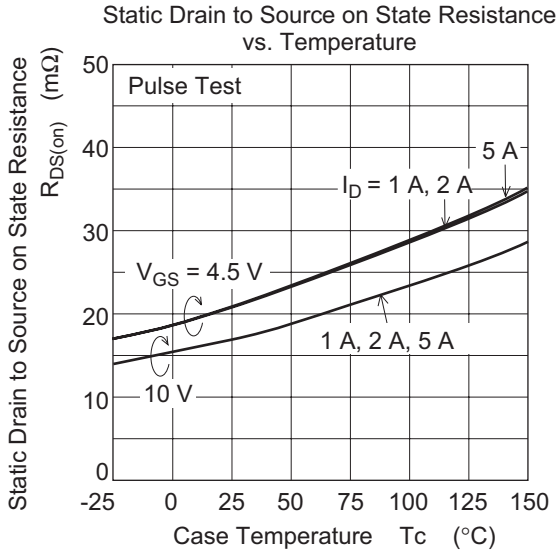


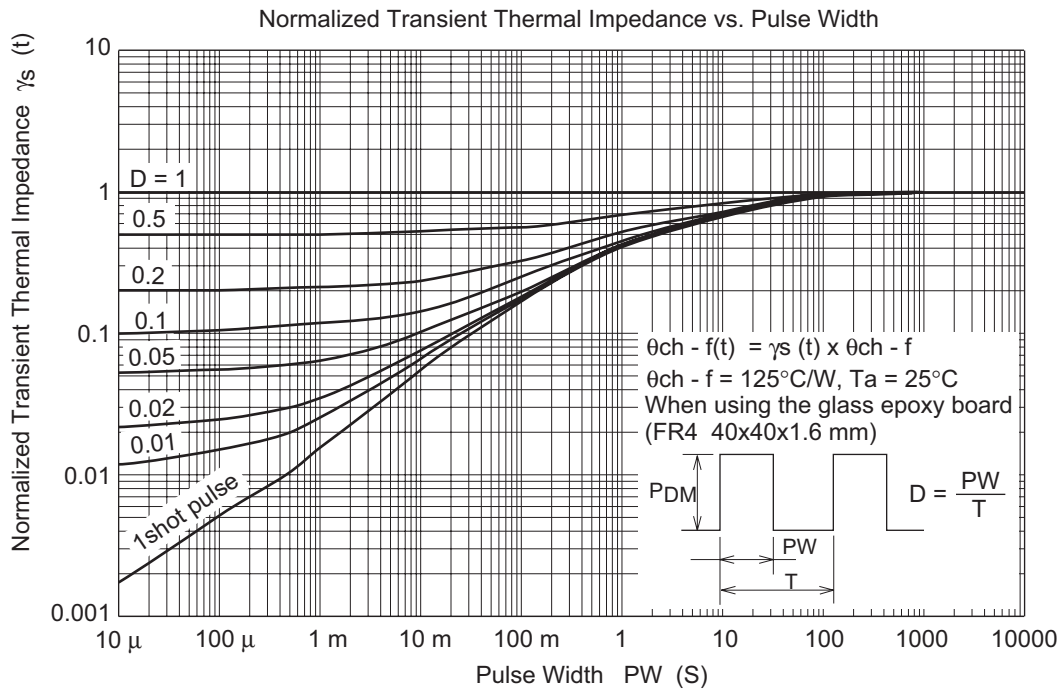
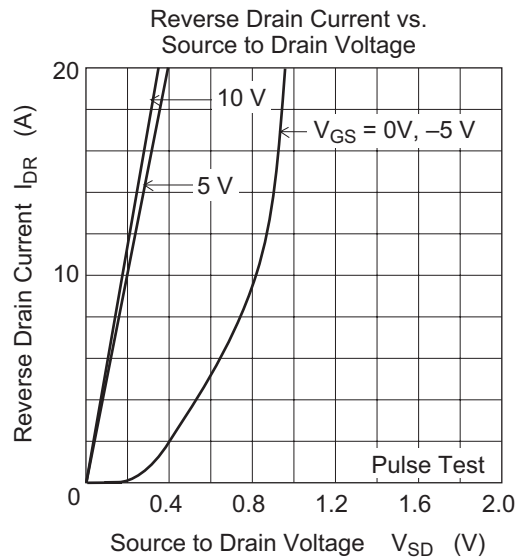
• MOS2 & Schottky Barrier Diode



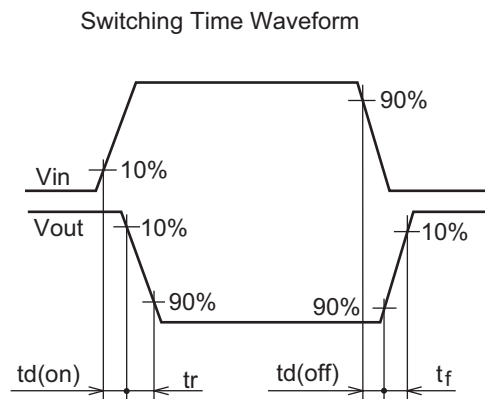
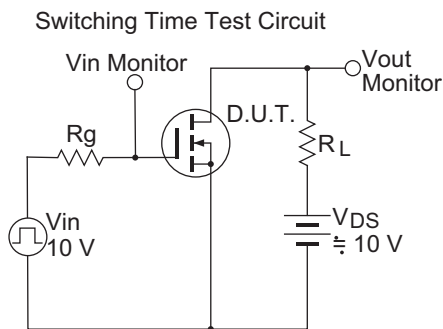
Note 4 :
When using the glass epoxy board (FR4 40x40x1.6 mm)





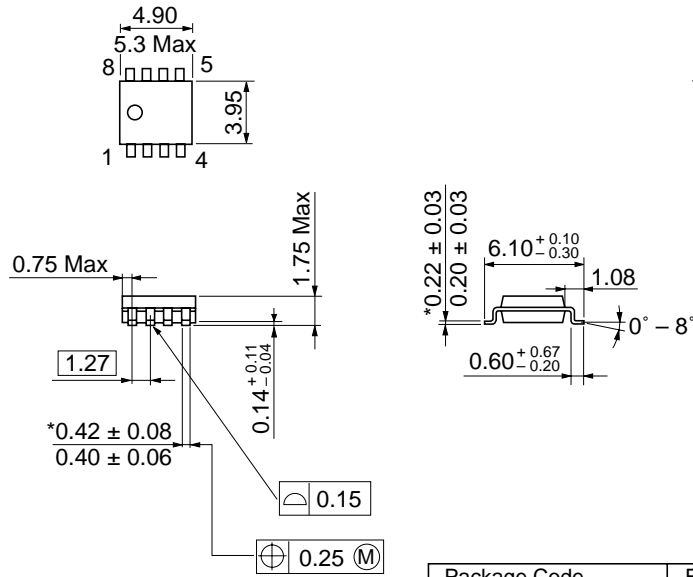


• Common



Package Dimensions

As of January, 2003
Unit: mm



*Dimension including the plating thickness
Base material dimension

Package Code	FP-8DA
JEDEC	Conforms
JEITA	—
Mass (reference value)	0.085 g

Ordering Information

Part Name	Quantity	Shipping Container
HAT2218R-EL-E	2500 pcs	Taping

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